CITY OF KIRKLAND
Planning and Building Department
123 Fifth Avenue, Kirkland, WA 98033 - (425) 587-3600
www.kirklandwa.gov

CITY OF KIRKLAND
NOTICE OF DECISION

March 21, 2016

Permit application:	Artoush Short Plat, SUB15-02347
Location:	11622 80th Avenue NE
Applicant:	Artoush Fanaiyan
Project description:	Proposal to subdivide a 1 acre parcel into 6 lots in a RSA 6 Zone. Access to the lots will be provided from a dedicated extension of the 80th Avenue NE right-of-way and a vehicular access tract. A public pedestrian easement along the northern edge of the property is also being proposed.
Decisions Included:	Short Plat (Process I)
Project Planner:	Tony Leavitt, Associate Planner
SEPA Determination:	Exempt
Department Decision:	**Approval with Conditions**

Eric Shields, Director
Department of Planning and Community Development

Decision Date:	March 17, 2016
Appeal Deadline:	April 4, 2016

Affected property owners may request a change in valuation for property tax purposes notwithstanding any program of revaluation.

How to Appeal: *Only the applicant or those persons who previously submitted written comments or information to the Planning Director are entitled to appeal this decision.* A party who signed a petition may not appeal unless such a party also submitted independent written comments or information. An appeal must be in writing and delivered, along with fees set by ordinance, to the Planning Department by 5:00 p.m, April 4, 2016. For information about how to appeal, contact the Planning Department at (425)587-3600. An appeal of this project decision would be heard by the City Council.

COMMENT TO CITY COUNCIL: If you do not file an appeal, but would like to express concerns about policies or regulations used in making this decision or about the decision making process, you may submit comments to citycouncil@kirklandwa.gov. Expressing your concerns in this way will not affect the decision on this application, but will enable the City Council to consider changes to policies, regulations or procedures that could affect future applications.